Formation and Rupture of Nanofilaments in Metal/TaO$_x$/Metal Resistive Switches

Mohini Verma

Thesis submitted to the faculty of the Virginia Polytechnic Institute and State University in partial fulfillment of the requirements for the degree of

Master of Science
In
Electrical Engineering

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September 4, 2012
Blacksburg, VA

Keywords: resistive switch, non-volatile memory, volatile switching, memristor

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Actually I am Mohini Verma and one of the authors of the paper "Volatile resistive switching in
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Thanks and Regards,
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Bradley Department of Electrical and Computer Engineering Virginia Tech Blackburg, VA 24060

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